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| U.S. Department of Commerce, Patent and Trademark Office | | | | Attorney Docket No. | | Serial No. | |
| | | | | T00071 | | 09/810,514 | |
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | | | Applicant(s) | | | |
| (Use several sheets if necessary) | | | | David Chao et al. | | | |
| | | | | Filing Date | | Group | |
| | | | | March 15, 2001 | | 3687 | |

| U.S. Patent Documents | | | | | | | |
|-----------------------|----|-----------------|------|------|-------|----------|----------------------------|
| *Examiner Initial | | Document Number | Date | Name | Class | Subclass | Filing Date If Appropriate |
| | AA | | | | | | |
| | AB | | | | | | |
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| Foreign Patent Documents | | | | | | | | |
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| | | | | | | | Translation | |
| | | Document | Date | Country | Class | Subclass | Yes | No |
| | An | | | | | | <input type="checkbox"/> | <input type="checkbox"/> |
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| OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.) | | |
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| | AS | Documents for U.S. Patent Application No. 09/896,144 in the U.S.P.T.O.'s Patent Application Information Retrieval (PAIR) system. |
| | AT | |

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| Examiner | Date Considered |
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